

Supporting Information

Enhanced Sensitivity in Self-Powered Dion-Jacobson Perovskite X-ray Detectors via a Ternary-Solvent-Ink Approach

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Figure S1. Optical microscope images of quasi-2D DJ perovskite films made by with single, binary, and ternary solvents.

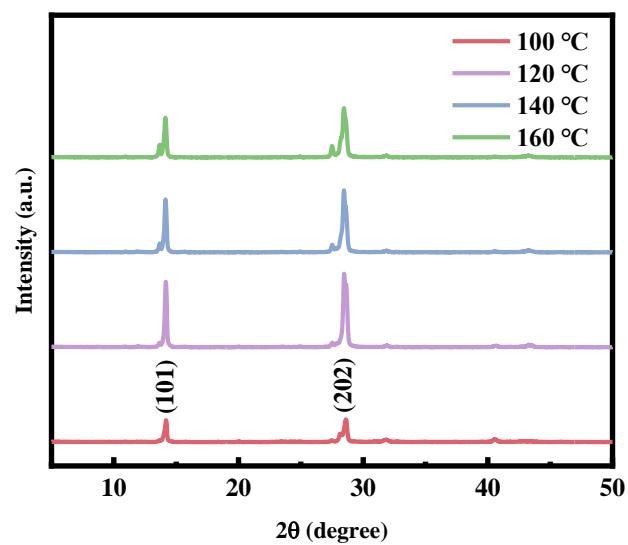


Figure S2. The XRD pattern of quasi-2D films made by ternary solvent ink strategy under different processing temperatures.

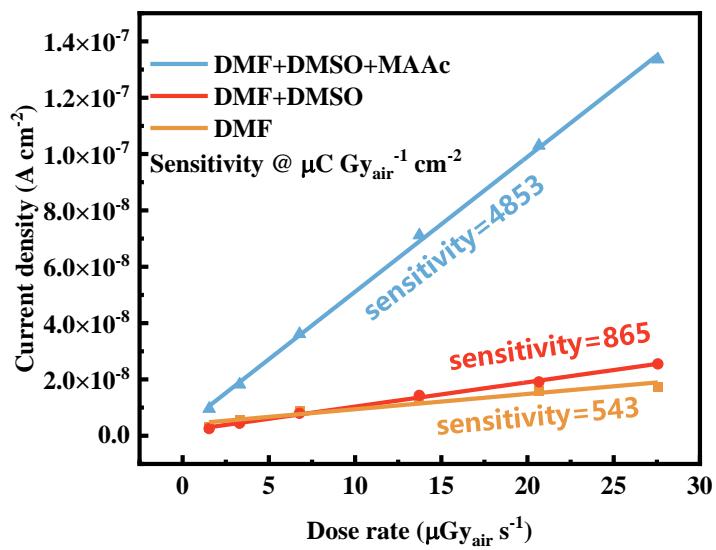


Figure S3. The sensitivity derived by linear fitting the dose rate dependent photocurrent of quasi-2D devices made by single, binary and ternary solvents .

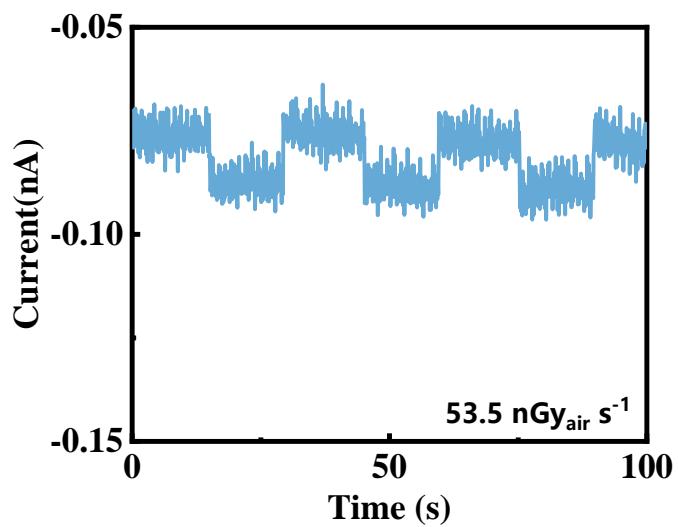


Figure S4. The photocurrent response of the target devices under on/ off X-ray illumination with the dose rate of $53.5 \text{ nGy}_{\text{air}} \text{ s}^{-1}$.

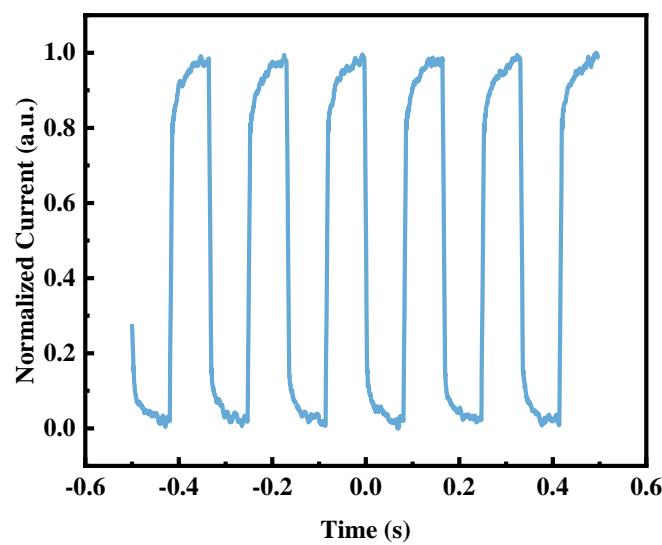


Figure S5. Temporal response of the $7 \mu\text{m}$ thick devices at 0 V bias under 532 nm LED illumination with a modulation frequency of 6 Hz.

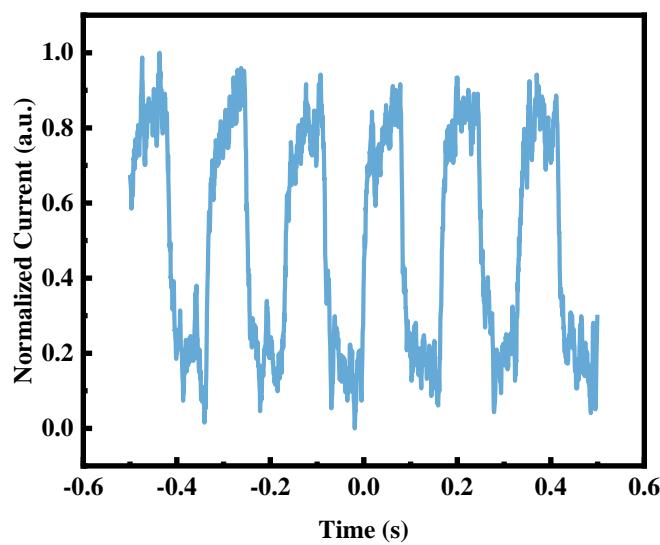


Figure S6. Temporal response of the 16 μm thick devices at 0 V bias under 532 nm LED illumination with a modulation frequency of 6 Hz.

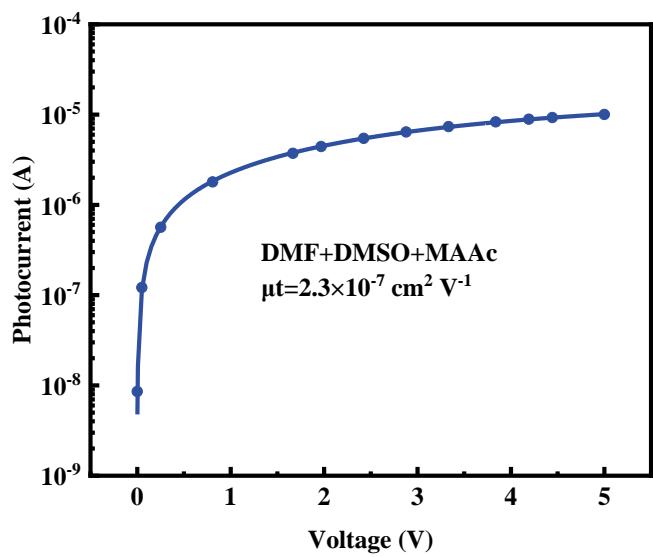


Figure S7. Voltage-dependent photocurrent curve of devices made by ternary solvents for the derivation of $\mu\tau$ product.

Table S1 Comparison of the device performance of different 2D perovskite X-ray detectors

Materials	Detection Limit (nGy _{air} s ⁻¹)	Sensitivity (μC Gy _{air} ⁻¹ cm ⁻²)	Working bias (V)
Cs ₂ Pb(SCN) ₂ Br ₂ film ¹	42.4	216.3	40
(S-BPEA) ₂ FAPb ₂ I ₇ SC ²	161	87.8	Self-driven
(4AMPY)(MA) ₃ Pb ₄ I ₁₃ /MAPbBr ₃ SC ³	77	1850	Self-driven
PEA ₂ MA ₄ Pb ₅ I ₁₆ film ⁴	22.7	236	30
CsPb ₂ Br ₅ SC ⁵	12.7	8865.6	50
EPZPbBr ₄ SC ⁶	<5.43	1240	10
(R/S-PPA)(IEA)PbBr ₄ SC ⁷	3	48.4	Self-driven
This work 7 μm	39	4853	Self-driven
This work 16 μm	27	8205	Self-driven

Reference

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